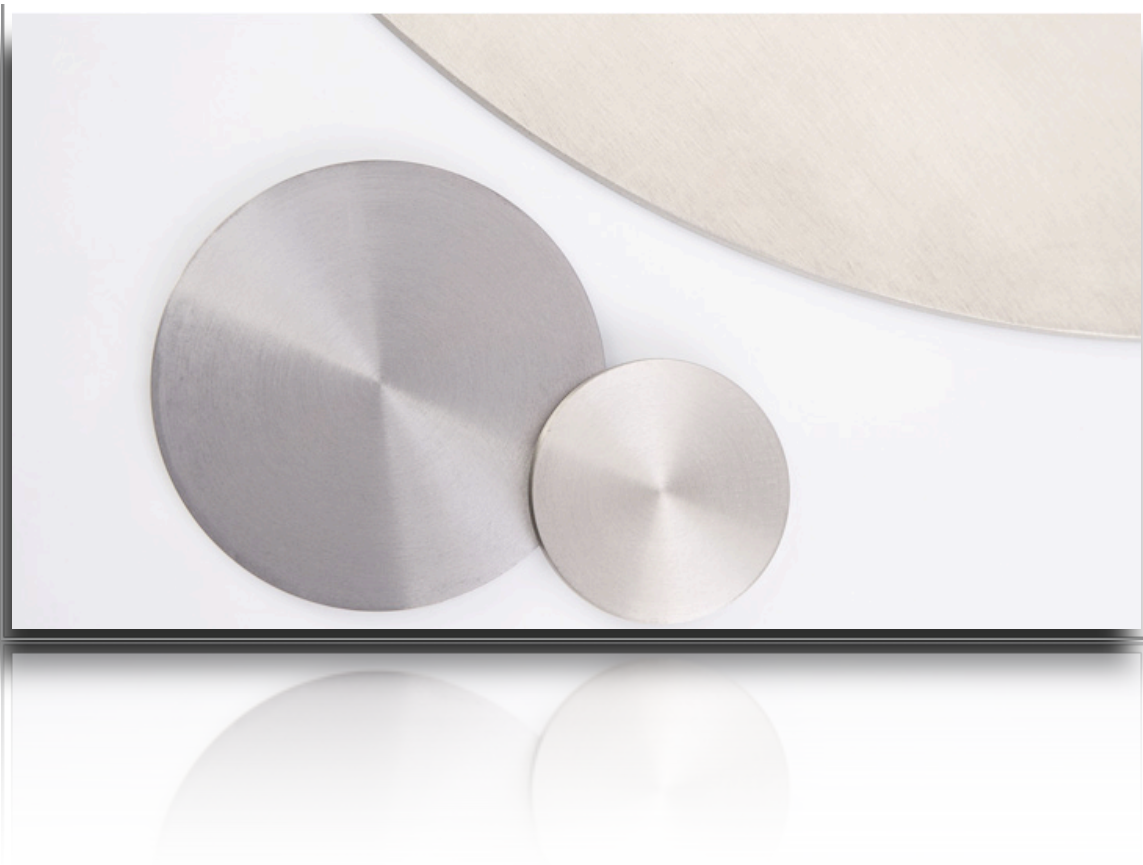


Sputtering Targets



Silicides

Material	Purity
Chromium Silicide	99,5 to 99,9%
Cobalt Silicide	99,5 %
Molybdenum Silicide	99,5 to 99,995%
Nickel Silicide	99,5 %
Niobium Silicide	99,5 %
Tantalum Silicide	99,5 %
Titanium silicide	99,5 to 99,95%
Tungsten Silicide	99,5 to 99,95%
Zirconium Silicide	99,5 %

The materials and sizes listed are available in stock. Other sizes and materials can be prepared upon request.